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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Hideki IWAKI

Application No. 09/994,683

Filed: November 28, 2001

For: MULTI-LEVEL CIRCUIT SUBSTRATE,  
METHOD FOR MANUFACTURING  
SAME AND METHOD FOR  
ADJUSTING A CHARACTERISTIC  
IMPEDANCE THEREFOR

Confirmation No. 8158

TC/Art Unit: 2826

Examiner: Leonardo Andujar

Atty Docket: P94916US1

Approved  
E. Andujar

**LETTER RESPONDING TO COMMUNICATION**

MAIL STOP ISSUE FEE  
Commissioner for Patents  
PO Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Office Communication dated May 27, 2004, please cancel the sheet of drawings containing Figure 14 and the duplicate copy of Figure 9.